

IX International MEMS Forum 2020

«Digital technology and wireless solutions»



Improving Yield in MEMS Manufacturing

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MEMS FORUM 2020

TOPIC OF THE YEAR:
"RELIABLE DIGITAL AND WIRELESS SOLUTIONS"

3 November
Moscow, IEC "Expocentre"
within the frame of SEMIEXPO Russia

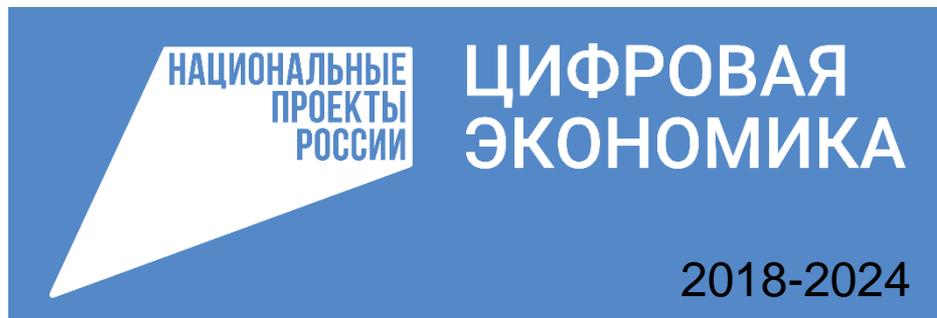
SOVTEST
BAZI PPAETHEP HO KAKTEBIX

SEMIEXPO
RUSSIA

The banner features a dark blue background with a network of white lines. On the left, there is a small image of a MEMS chip and logos for SOVTEST and SEMIEXPO RUSSIA. The main text is in white and yellow, providing details about the forum's topic, date, and location.



National programs of Digitalization



National program “Digital economy”

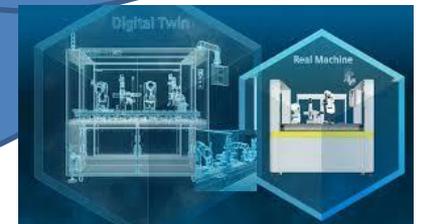
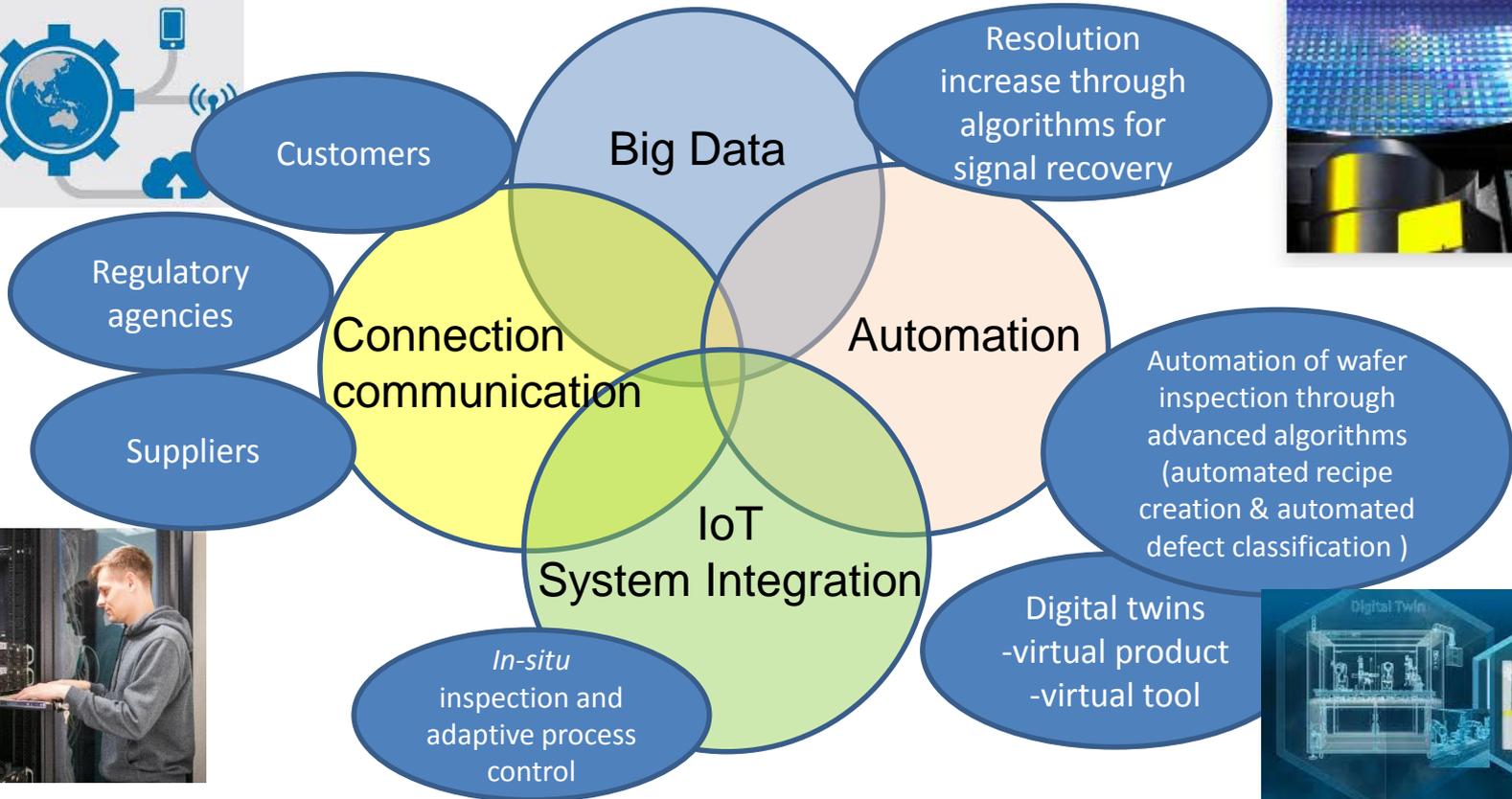
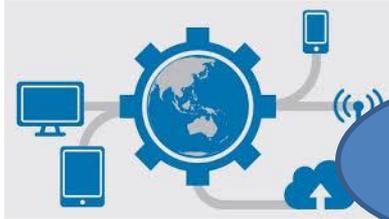
Federal Projects related to the industry:

- Information security / Информационная безопасность,
- Digital technology / Цифровые технологии,
- Digital state management / Цифровое государственное управление





Role of digital technology and wireless solutions/ Роль цифровых технологий и беспроводных решений





Role of automatization in MEMS Fab
yield increase /

Роль автоматизации в увеличении
выхода годных на МЭМС
производстве



Introduction - MAPPER LLC

mapperllc.ru



Mapper is a MEMS foundry

We offer

- technology development for realization of MEMS design
- production line of automated tools for manufacturing small and medium sized series



Mapper Fab has
cleanroom
- ISO 6
- 1500 m²

Fab yield increase by defect reduction/ Увеличение выхода годных за счет сокращения дефектов



1

Wafer incoming
inspection

Tool contamination
monitoring

Defect detection system
during the early phases
of the product life cycle

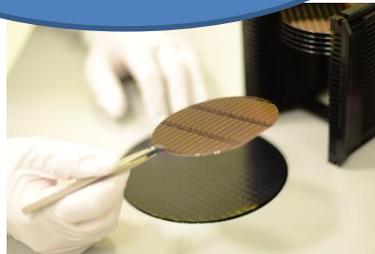
Входной
контроль пластин

2

Контроль чистоты
процессов,
оборудования

3

Система обнаружения
дефектов на ранних
стадиях производства

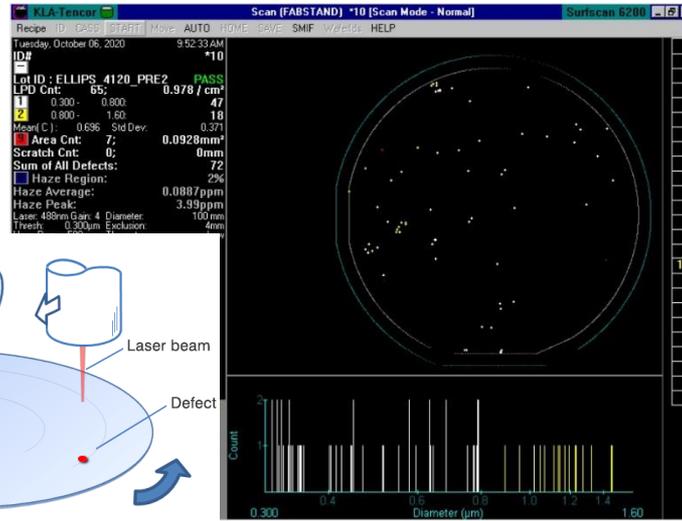
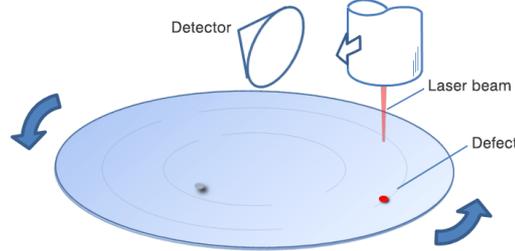




1. Wafer incoming inspection/ Входной контроль пластин



Счетчик частиц на пластинах
KLA SurfScan6200,
автоматическая подача
пластин

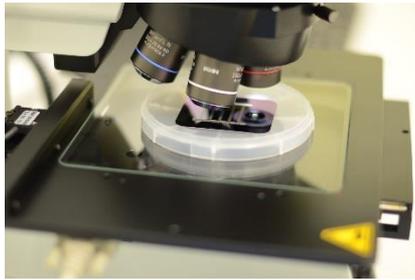


2. Tool contamination monitoring/ Контроль чистоты процессов, оборудования

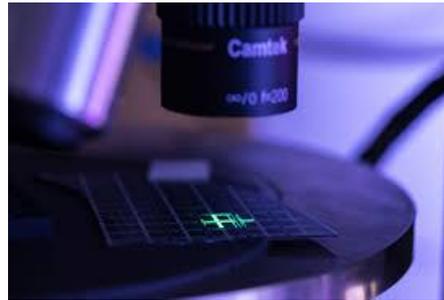
- weekly tool/processes contamination monitoring



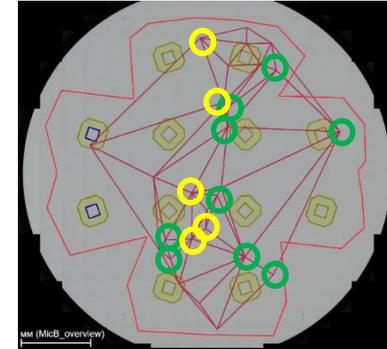
3. Defect detection system/ Система обнаружения дефектов



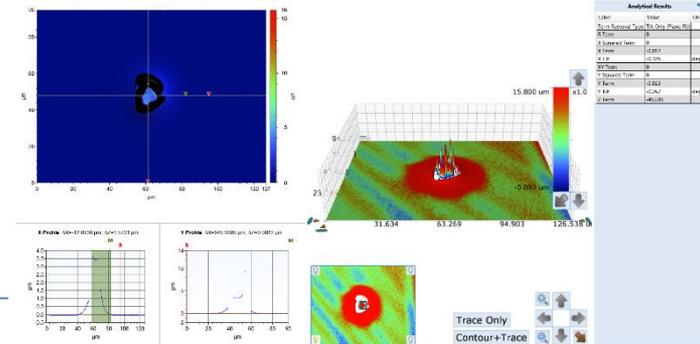
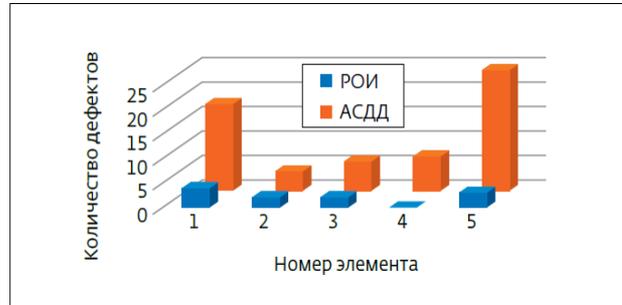
manual inspection



automated inspection



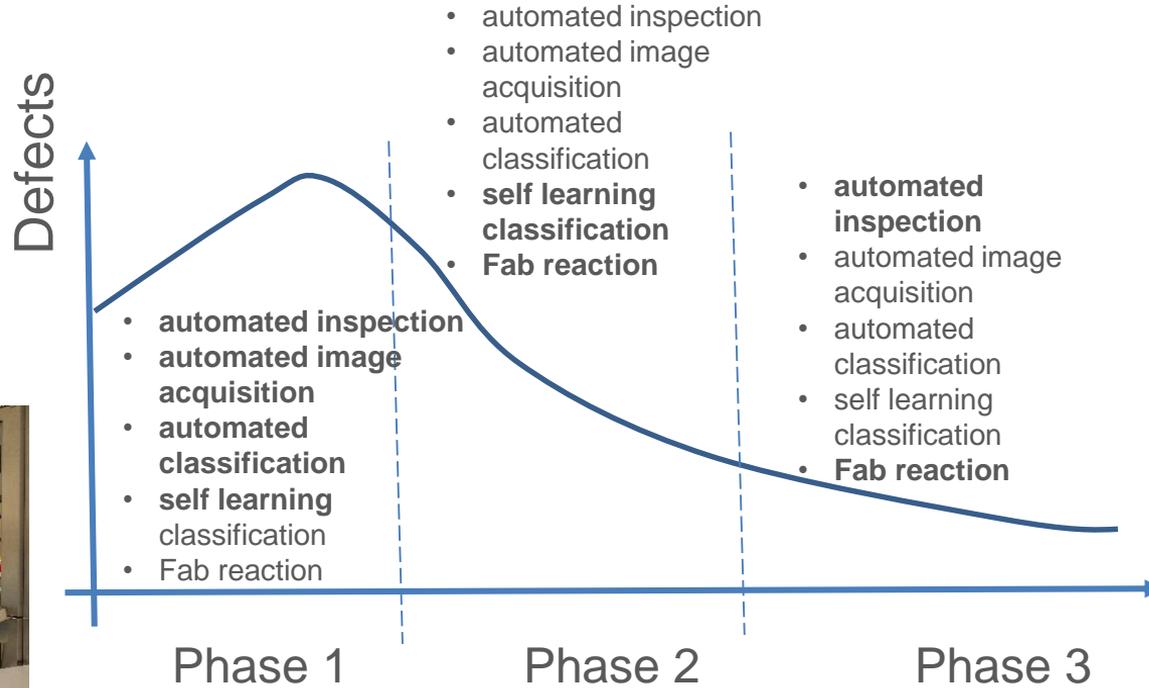
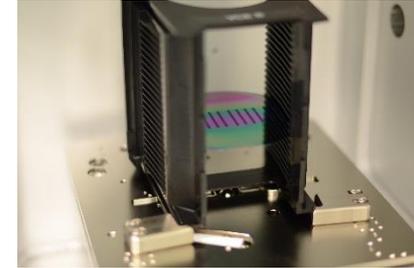
- automated analysis
- automated classification
- self learning classification



Automated defect detection system in MEMS manufacturing. K.Raketov, N.Israilev, A.Kazachkov, E.Zablotskaya, I.Rod, M.Ryabkov, A.Isachenko, D.Shamiryar. **NANOINDUSTRY**. Vol. 11 No. 7–8 (86) 2018.



Implementation of automated litho defect detection system/ Внедрение автоматизированной системы обнаружения дефектов литографии



Thank you for your attention!
Спасибо за внимание!

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